DO NOT ENTER: /CAM/

## **PATENT**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/797,876 Applicant: Dip et al. Art Unit: 2811

Title: SILICON GERMANIUM SURFACE LAYER FOR HIGH-K

**DIELECTRIC INTEGRATION** 

Attorney Docket: TPS-007 Confirmation No.: 5070

August 4, 2008

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## **AMENDMENT - AFTER FINAL REJECTION**

This paper is responsive to the Office Action mailed June 3, 2008, made final per MPEP § 706.07(a). The present response includes the following:

Amendments to the Specification: None

Amendments to the Claims: Pages 2-5

Amendments to the Abstract: None
Amendments to the Drawings: None

Remarks: Pages 6-11

Attachments: None